EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
5195	43643	phenyltrimethoxysilane or phenyltricthoxysilane or propyhnethyldimethoxysilane or methyl orthosilicate or n-propyl orthosilicate or tetrabutyl glycol orthosilicate or amyltrimethoxysilane or bis (methyltriethyleneglycol)dimethylsilane or 2-(cyclohex 3-enyl)ethyltriethoxysilane or cyclohexylmethyldimethoxysilane or cyclohexylmethyldimethoxysilane or cyclopentylnethyldimethoxysilane or cyclopentyltrimethoxysilane or di-i-butyldimethoxysilane or di-i-butyldimethoxysilane or di-i-butyldimethoxysilane or di-i-propyldimethoxysilane or dimethyldiethoxysilane or 2-phenylethyltriethoxysilane or 2-phenylethyltriethoxysilane or 2-phenylethyltriethoxysilane or 3-methacryloxypropyltrimethoxysilane or 3-methacryloxypropyltrimethoxysilane or 3-acryloxy-2-methyl-propyldimethoxysilane or 3-acryloxy-2-methylpropyldimethoxysilane or methylpropyldimethoxysilane or methylpropyldimethoxysilane or trimethoxysilane, triethoxysilane or dimethylethoxysilane or triethylsilane or methyltriacetoxysilane or triethylsilane or methyltriacetoxysilane or or hoptamethyldisilazane or hexamethyldisilazane or hoptamethyldisilazane or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or 1,3-acetoxypropyltrimethoxysilane or trimethylsilyl acetate or 3-azido-propyltriethoxysilane or 3-aminopropyltrimethoxysilane or 3-aminopropyltriethoxysilane or 3-acyanatopropyltriethoxysilane or 3-isocyanatopropyltriethoxysilane or 3-isocyanatopropyltrimethoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:29
S196	8781	S195 and ("427"/\$.ccls. or CVD or vapor deposition)	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:29
 6197	4661	S196 and (silicon dioxide or "sio.sub.2")	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:30
S198	0	"2002019282"	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:31

S199	125	andideh.in.	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:32
S200	43649	phenyltrimethoxysilane or phenyltricthoxysilane or propyhnethyldimethoxysilane or methyl orthosilicate or n-propyl orthosilicate or tetrabutyl glycol orthosilicate or amyltrimethoxysilane or bis (methyltriethyleneglycol)dimethylsilane or 2-(cyclohex 3-enyl) ethyltriethoxysilane or cyclohexylmethyldimethoxysilane or cyclohexylmethyltrimethoxysilane or cyclopentyhnethyldimethoxysilane or cyclopentyhnethyldimethoxysilane or douglenethyltrimethoxysilane or douglenethyltrimethoxysilane or douglenethyldimethoxysilane or diphonyldimethoxysilane or diphonyldimethoxysilane or diphonyldimethoxysilane or diphonyldimethoxysilane or diphonyldimethoxysilane or diphonyldimethoxysilane or dimethyldiethoxysilane or 2-phenylethylnethyldiethoxysilane or 3-methacryloxyropyltrimethoxysilane or 3-methacryloxyropyltrimethoxysilane or 3-methylpropyldimethoxysilane or 3-methylpropyldimethoxysilane or 3-acryloxy-2-methylpropyldimethoxysilane or methylpropyldimethoxysilane or triethylsilane or dimethylethoxysilane or triethylsilane or methyltriacetoxysilane or triethylsilane or methyltriacetoxysilane or triethylsilane or methyltriacetoxysilane or ditert-butoxydiacetoxysilane or inspective or diphonyltriacetoxysilane or 1,3-divinyltetramethyldisilazane or hexamethyldisilazane or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or 3-acctoxypropyltriethoxysilane or 3-acctoxypropyltriethoxysilane or trimethylsilyl acetate or 3-azido-propyltriethoxysilane or 3-aminopropyltriethoxysilane or 3-acctoxynatopropyltriethoxysilane or 3-acctoxynatopropyltriethoxysilane or 3-acctoxynatopropyltriethoxysilane or 3-acctoxynato	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:34
S201	3	S195 and andideh.in.	US- PGPUB;	ADJ	ON	2011/02/28 21:35

S202	37561	phenyltrimethoxysilane or phenyltricthoxysilane or propyhnethyldimethoxysilane or methyl orthosilicate or n-propyl orthosilicate or dicyclopentyldimethoxysilane or dimethyldiethoxysilane or vinyltriacetoxysilane or 2-phenylethyltriethoxysilane or methyldiethoxysilane or methylpropyldimethoxysilane or methylpropyldimethoxysilane or trimethoxysilane, triethoxysilane or dimethylethoxysilane or triethylsilane or methyltriacetoxysilane or ethyltriacctoxysilane or vinyltriacetoxysilane or ethyltriacctoxysilane or or heptamethyldisilazane or hexamethyldisilazane or hexamethyldisilazane or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or trimethylsilyl nitrile or 3-cyanatopropyltrimethoxysilane or 3-isocyanatopropyltrimethoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:36
S203	805	propyhnethyldimethoxysilane or methyl orthosilicate or n-propyl orthosilicate or dicyclopentyldimethoxysilane or dimethyldiethoxysilane or vinyltriacetoxysilane or 2-phenylethyltriethoxysilane or methyldiethoxysilane or methylpropyldiethoxysilane or methylpropyldimethoxysilane or trimethoxysilane, triethoxysilane or dimethylethoxysilane or triethylsilane or methyltriacetoxysilane or triethylsilane or methyltriacetoxysilane or ethyltriacctoxysilane or vinyltriacetoxysilane or ditert-butoxydiacetoxysilane or hexamethyldisilazane or hexamethyldisilazane or N,O-bis(trimethylsilyl)acetamide or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or trimethylsilyl nitrile or 3-cyanatopropyltrimethoxysilane or 3-cyanatopropyltrimethoxysilane) same (CVD or vapor deposition)	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:36
S204	399	(phenyltrimethoxysilane or phenyltricthoxysilane or propyhnethyldimethoxysilane or methyl orthosilicate or n-propyl orthosilicate or dicyclopentyldimethoxysilane or dimethyldiethoxysilane or vinyltriacetoxysilane or 2-phenylethyltriethoxysilane or methyldiethoxysilane or methylpropyldiethoxysilane or methylpropyldimethoxysilane or trimethoxysilane, triethoxysilane or dimethylethoxysilane or triethylsilane or methyltriacetoxysilane or ethyltriacetoxysilane or ethyltriacetoxysilane or or ethyltriacetoxysilane or ditert-butoxydiacetoxysilane or hexamethyldisilazane or hexamethyldisilazane or N,O-bis(trimethylsilyl)acetamide or 1,3-divinyltetramethyldisiloxane or 1,3-divinyltetramethyldisiloxane or trimethylsilyl nitrile or 3-cyanatopropyltrimethoxysilane or 3-cyanatopropyltriethoxysilane or 3-isocyanatopropyltrimethoxysilane) same (CVD or vapor deposition) same (silicon \$20xide or "sio. sub.2")	US- PGPUB; USPAT	ÎADJ	NON	2011/02/28 21:37

S205	45	S204 and "427"/\$.ccls.	US- PGPUB; USPAT	ADJ	ON	2011/02/28 21:38
S206	40	MTAS and "427"/\$.ccls.	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:03
S207	25	MTAS and "427"/\$.ccls. and (silicon dioxide or "sio. sub.2" or silica)	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:03
S208	14134	orthosilicate	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:24
S210	119	orthosilicate with trimethoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:25
S211	137	arylalkoxysilane or alkylarylalkoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:26
S212	19	09/111083	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:27
S213	1278	methyltriacetoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:38
S214	106	methyltriacetoxysilane with acetoxysilane	US- PGPUB; USPAT	ADJ	ON	2011/02/28 22:39

EAST Search History (Interference)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S215		vinyltrimethoxysilane or vinyltriethoxysilane or vinyltris (methoxyethoxy)silane or vinylmethyldialkoxysilane or vinylarylalkoxysilanes or methyltrimethoxysilane or ethyltrimethoxysilane or ethyltriethoxysilane	US-PGPUB; USPAT; UPAD	ADJ	ON	2011/02/28 21:22
S216	447	S215 and (SiO2 or silicon dioxide) and CVD	US-PGPUB; USPAT; UPAD	ADJ	ON	2011/02/28 21:22
S217		S216 and (methyltrimethoxysilane or ethyltrimethoxysilane or ethyltriethoxysilane) same (Sio2 or "sio. sub.2" or silicon \$20xide)	US-PGPUB; USPAT; UPAD	ADJ	ON	2011/02/28 21:22

3/1/2011 8:10:25 AM

C:\ Documents and Settings\ jmiller5\ My Documents\ EAST\ Workspaces\ 10-586675 restrict.wsp